



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of : Confirmation No. 9616  
Koji MISHIMA et al. : Docket No. 2001-1323A  
Serial No. 09/955,115 : Group Art Unit 1741  
Filed September 19, 2001 : Examiner Wong, Edna

PLATING METHOD AND PLATING APPARATUS

RESPONSE TO RESTRICTION REQUIREMENT

Assistant Commissioner for Patents,  
Washington, D.C.

THE COMMISSIONER IS AUTHORIZED  
TO CHARGE ANY DEFICIENCY IN THE  
FEES FOR THIS PAPER TO DEPOSIT  
ACCOUNT NO. 23-0975

Sir:

This is in response to the Restriction Requirement of March 12, 2003.

Applicants, by their undesignated representative, hereby elect the invention of Group I which is drawn to a plating method and corresponds to claims 1-6.

Having made the required election, a full examination on the merits of the elected invention is hereby requested.

Respectfully submitted,

Koji MISHIMA et al.

By:

*Joseph M. Gorski*

Joseph M. Gorski  
Registration No. 46,500  
Attorney for Applicants

JMG/adb  
Washington, D.C. 20006-1021  
Telephone (202) 721-8200  
Facsimile (202) 721-8250  
April 9, 2003

#  
6/wm.  
6/4/11/03  
RECEIVED  
APR 11 2003  
GROUP 1700